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Optoelectronic Devices and Integration

**Zishen Zhao
Ray Chen
Yong Chen
Jinzhong Yu
Junqiang Sun**
Editors

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Contents

vii	Symposium Committees
xi	Conference Committee

OPTOELECTRONICS DEVICES AND INTEGRATION

7516 02	A third-order silicon microring add-drop filter with high extinction ratios [7516-26] X. Xiao, Q. Huang, Y. Li, Z. Fan, W. Han, Y. Yu, J. Yu, Institute of Semiconductors (China)
7516 03	Birefringence and formed birefringence in photonic crystal line waveguides [7516-41] W. Zhang, Xi'an Institute of Optics and Precision Mechanics (China) and Graduate School of the Chinese Academy of Sciences (China); J. Liu, Xi'an Institute of Post and Telecommunications (China); W.-P. Huang, McMaster Univ. (Canada); W. Zhao, Xi'an Institute of Optics and Precision Mechanics (China)
7516 04	Electronic dispersion compensation for high speed long haul transmission with DQPSK modulation [7516-31] L. Lu, Huazhong Univ. of Science and Technology (China) and Air Force Radar Academy (China); J. Lei, X. Luo, L. Bing, Huazhong Univ. of Science and Technology (China)
7516 05	Error rate performance of atmospheric laser communication based on bubble model [7516-25] K. Xu, J. Wang, Huazhong Univ. of Science and Technology (China); Y. Li, Chongqing Univ. of Technology (China)
7516 06	Fabrication of silicon photonic devices by utilizing industrial CMOS technology [7516-13] Y. Zhao, H. Zhou, W. Wang, J. Yang, M. Wang, X. Jiang, Zhejiang Univ. (China)
7516 07	Flat-top passband filter based on parallel-coupled double microring resonators in silicon [7516-33] Q. Huang, X. Xiao, Y. Li, Z. Li, Y. Yu, J. Yu, Institute of Semiconductors (China)
7516 08	High channel-count phase-only sampled fiber Bragg grating and its application to dispersion compensator and multi-wavelength fiber laser (Invited Paper) [7516-01] H. Li, Shizuoka Univ. (Japan)
7516 09	High color rendering index WLED based on YAG:Ce phosphor and CdS/ZnS core/shell quantum dots [7516-23] C. Shen, K. Li, China Jiliang Univ. (China)
7516 0A	High efficiency Silicon-on-Insulator grating coupler between submicron waveguides and fibers [7516-37] Y. Zhu, Z. Li, W. Han, Z. Fan, Y. Yu, J. Yu, Institute of Semiconductors (China)

- 7516 OB **Inductively coupled plasma etching of SOI and its applications in submicron optical waveguide devices** [7516-40]
Z. Fan, W. Han, F. Yang, X. Xu, Q. Huang, X. Xiao, Y. Zhu, Y. Li, Z. Li, Y. Yu, J. Yu, Institute of Semiconductors (China)
- 7516 OC **Mach-Zehnder electro-optic modulator based on silicon nanophotonic waveguide** [7516-10]
X. Xu, H. Xu, Institute of Semiconductors (China); Z. Fan, Engineering Research Ctr. for Semiconductor Integrated Technology (China); Y. Yu, J. Yu, Institute of Semiconductors (China)
- 7516 OD **Modeling of reflecting sinusoidal uniform phase volume diffractive gratings** [7516-47]
Y. Yi, Huazhong Univ. of Science and Technology (China) and Wuhan Univ. of Technology (China); D. Liu, Huazhong Univ. of Science and Technology (China)
- 7516 OE **Optical properties of amorphous $\text{Ba}_{0.7}\text{Sr}_{0.3}\text{TiO}_3$ thin films obtained by metal organic decomposition technique** [7516-36]
F. Qiu, Z. Xu, Huazhong Univ. of Science and Technology (China)
- 7516 OF **Optical property of BaTiO_3 ferroelectric film at room temperature** [7516-44]
Y. Fu, X. Zhang, Z. Xu, Huazhong Univ. of Science and Technology (China)
- 7516 OG **Opto-VLSI-based broadband true-time delay generation for phased array beamforming** [7516-43]
B. Juswardy, F. Xiao, K. Alameh, Edith Cowan Univ. (Australia)
- 7516 OH **Opto-VLSI-based reconfigurable photonic RF filter** [7516-39]
F. Xiao, M. Shen, B. Juswardy, K. Alameh, Edith Cowan Univ. (Australia)
- 7516 OI **Performance optimisation of reconfigurable optical add-drop multiplexers employing Opto-VLSI processors** [7516-34]
M. Shen, F. Xiao, K. Alameh, Edith Cowan Univ. (Australia)
- 7516 OJ **Periodical polymer grating structure with high aspect ratio** [7516-42]
J.-K. Kuo, W.-C. Chang, Southern Taiwan Univ. of Technology (Taiwan, China); K.-F. Yarn, Far East Univ. (Taiwan, China); W.-C. Chuang, National Formosa Univ. (Taiwan, China)
- 7516 OK **Polarization coupling of optical pulse in birefringent nonlinear waveguide** [7516-11]
W. Wang, J. Zhang, Hubei Univ. (China); Y. Wang, Liteon Singapore Pte Ltd. (Singapore)
- 7516 OL **Preparation and photoluminescence properties of porous silicon** [7516-45]
Z. Chen, Z. Xu, Wuhan National Lab. for Optoelectronics (China) and Huazhong Univ. of Science and Technology (China)
- 7516 OM **Proposal and analysis of a double-tip coupler for efficient coupling fiber to slot and strip waveguides** [7516-35]
Q. Huang, W. Han, Z. Fan, F. Yang, Y. Liu, X. Xiao, Y. Zhu, Y. Li, Z. Li, Y. Yu, J. Yu, Institute of Semiconductors (China)

- 7516 ON **Raman spectroscopy of aged rare earth doped ormosils** [7516-46]
V. Ranga, Government College Ajmer (India); H. N. Acharya, Indian Institute of Technology (India); R. K. Khanna, BMIT Jaipur (India); A. Kumar, Chino Scientific Instruments Manufacturing (India)
- 7516 OO **Recent advances on chip-to-chip optical interconnect (Invited Paper)** [7516-51]
D. Lu, Henkel Electronics (China)
- 7516 OP **Simulation of a 1550-nm InGaAsP-InP transistor laser** [7516-19]
W. Shi, Univ. of British Columbia (Canada); Z. Duan, Shenzhen Univ. (China); R. Vafaei, N. Rouger, B. Farji, L. Chrostowski, Univ. of British Columbia (Canada)
- 7516 OQ **Simulation of optically switchable and tunable ultrawideband monocycle generation using semiconductor optical amplifier and optical delay line** [7516-48]
Z. Hu, J. Sun, J. Shao, Huazhong Univ. of Science and Technology (China)
- 7516 OR **SOI based waveguide devices (Invited Paper)** [7516-28]
J. Yu, Q. Huang, X. Xu, X. Xiao, Y. Zhu, Y. Liu, Z. Li, Y. Li, Z. Fan, Y. Yu, Institute of Semiconductors (China)
- 7516 OS **Spectrum analysis technique for measuring time delay of light in SOI micro-ring slow light device** [7516-50]
D. Yang, Central Univ. for Nationalities (China); Y. Li, Z. Fan, Semiconductor Institute (China); X. Chen, S. Feng, M. Lv, Y. Yang, Central Univ. for Nationalities (China)
- 7516 OT **Study on the optical property of the micro Fabry-Perot cavity tunable filter** [7516-15]
Q. Meng, Huazhong Univ. of Science and Technology (China), Wuhan National Lab. for Optoelectronics (China), and Guangxi Teachers Education Univ. (China); S. Chen, L. Wu, S. Dong, S. Bao, Huazhong Univ. of Science and Technology (China) and Wuhan National Lab. for Optoelectronics (China)
- 7516 OU **The negative refraction of the 2D triangular lattice of air hole in silicon** [7516-14]
C. Wu, J. Wu, T. Hong, Y. Li, Z. Wang, Peking Univ. (China)
- 7516 OV **Thin films' thickness uniformity associated with the method of electron beam evaporation** [7516-06]
Z. Xia, Y. Xue, P. Guo, Z. Li, Wuhan Univ. of Technology (China)
- 7516 OW **White light emitting diode based on InGaN chip with core/shell quantum dots** [7516-17]
C. Shen, China Jiliang Univ. (China); Y. Hong, J. Ma, Changqing Oil Field Co., Ltd (China); J. Ming, HangZhou DaMing Fluorescent Material Co., Ltd (China)
- 7516 OX **Multi-channel all-optical format conversions from RZ signals with different duty-cycle to NRZ signals** [7516-16]
Y. Yu, X. Zhang, C. Cheng, D. Huang, Huazhong Univ. of Science and Technology (China)
- 7516 OY **A microwave photonic notch filter based on semiconductor optical amplifier and optical filter** [7516-22]
E. Xu, X. Zhang, X. Li, L. Zhou, Y. Zhang, Y. Yu, F. Wang, D. Huang, Huazhong Univ. of Science and Technology (China)

- 7516 0Z **A novel L-band multiwavelength mode-locked semiconductor fibre laser** [7516-32]
F. Wang, Huazhong Univ. of Science and Technology (China) and Chongqing Univ. of
Technology (China); X. Zhang, E. Xu, Y. Zhang, Huazhong Univ. of Science and Technology
(China)
- 7516 10 **Design of self-collimating photonic crystal polarization beam splitter** [7516-12]
J. Li, F. Li, Suzhou Institute of Nano-Tech and Nano-Bionics (China)

Author Index

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